

**ELEG 667–016; MSEG-667-016 - Solid State Nanoelectronics – Fall 2005
Solutions**

Homework #5 - due Tuesday, 17 October 2005, in class

1.

The maximum demagnetization field in a Néel wall is $-4\pi M_s$, (in cgs units) and the maximum self-energy density is $\frac{1}{2}(4\pi M_s)M_s$. In a wall of thickness Na , where a is the lattice constant, the demagnetization contribution to the surface energy is $\sigma_{\text{demag}} \approx 2\pi M_s^2 Na$. This is a type of anisotropy energy. The total wall energy, exchange + demag, is $\sigma_w \approx (\pi^2 JS^2/Na^2) + (2\pi M_s^2 Na)$, by use of $(\sigma_w = \sigma_{\text{ex}} + \sigma_{\text{anis}})$. The minimum is at

$$\begin{aligned} \partial\sigma_w/\partial N = 0 &= -\pi^2 JS^2/N^2 a^2 + 2\pi M_s^2 a, \text{ or} \\ N &= \left(\frac{1}{2}\pi JS^2/M_s^2 a^3\right)^{1/2}, \end{aligned}$$

and is given by

$$\sigma_w \approx \pi M_s S (2\pi J/a)^{1/2} \approx (10)(10^3)(10^{-4}/10^{-8})^{1/2} \approx 10 \text{ erg/cm}^2,$$

which is larger than (1 erg/cm^2) for iron. (According to Table 8.1 of the book by R. M. White and T. H. Geballe, the Bloch wall thickness in Permalloy (20% iron and 80% nickel) is 16 times that in iron; this large value of δ favors the changeover to Néel walls in thin films.)

2. $M_A T = C(B - \mu M_B - \varepsilon M_A)$ (B = applied field)
 $M_B T = C(B - \varepsilon M_B - \mu M_A)$

Non-trivial solution for $B = 0$ if

$$\begin{vmatrix} T + \varepsilon C & \mu C \\ \mu C & T + \varepsilon C \end{vmatrix} = 0; T_C = C(\mu - \varepsilon)$$

Now find $\chi = (M_A + M_B)/B$ at $T > T_C$:

$$\begin{aligned} MT &= 2CH - CM(\varepsilon + \mu); \chi = \frac{2C}{T + C(\mu + \varepsilon)} \\ \therefore \theta/T_C &= (\mu + \varepsilon)/(\mu - \varepsilon). \end{aligned}$$